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## Front Matter: Volume 6831

, "Front Matter: Volume 6831," Proc. SPIE 6831, Nanophotonics, Nanostructure, and Nanometrology II, 683101 (14 March 2008); doi: 10.1117/12.783501

**SPIE.**

Event: Photonics Asia 2007, 2007, Beijing, China

# PROCEEDINGS OF SPIE

## ***Nanophotonics, Nanostructure, and Nanometrology II***

**Xing Zhu**  
**Stephen Y. Chou**  
**Yasuhiko Arakawa**  
*Editors*

**12–14 November 2007**  
**Beijing, China**

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**Volume 6831**

Proceedings of SPIE, 0277-786X, v. 6831

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Author(s), "Title of Paper," in *Nanophotonics, Nanostructure, and Nanometrology II*, edited by Xing Zhu, Stephen Y. Chou, Yasuhiko Arakawa, Proceedings of SPIE Vol. 6831 (SPIE, Bellingham, WA, 2007) Article CID Number.

ISSN 0277-786X  
ISBN 9780819470065

Published by

**SPIE**

P.O. Box 10, Bellingham, Washington 98227-0010 USA  
Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445  
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